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## D isorder-induced melting of the charge order in thin $\,$ lm s of P $r_{0.5}$ C $a_{0.5}$ M nO $_3$

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A bstract. { We have studied the magnetic-ekd-induced melting of the charge order in thin Im s of Pr<sub>0:5</sub>Ca<sub>0:5</sub>M nO<sub>3</sub> (PCMO) Im s on SrTiO<sub>3</sub> (STO) by X-ray di raction, magnetization and transport measurement. At small thickness (25 nm) the Im s are under tensile strain and the low-temperature melting ekds are of the order of 20 T or more, comparable to the bulk value. W ith increasing Im thickness the strain relaxes, which leads to a strong decrease of the melting ekds. For a Im of 150 nm, with in-plane and out-ofplane lattice parameters closer to the bulk value, the melting ekd has reduced to 4 T at 50 K, with a strong increase in the hysteretic behavior and also an increasing fraction of ferrom agnetic material. Strain relaxation by grow th on a template of YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub> or by post-annealing yields sim ilar results with an even stronger reduction of the melting ekd. Apparently, strained Im s behave bulk-like. R elaxation leads to increasing suppression of the CO state, presum ably due to atom ic scale disorder produced by the relaxation process.

Introduction. { The occurrence of Charge O rder (CO) in doped perovskite m anganites of type RE<sub>1 x</sub> A<sub>x</sub>M nO<sub>3</sub> (RE = trivalent rare earth ,A '= divalent alkaline earth) is currently a much studied phenom enon. The CO state, a long range ordering of the M n<sup>3+</sup> and M n<sup>4+</sup> ions, is the result of a complicated competition between C oulom b interactions (between the charges), exchange interactions (between the M n m om ents), and the electron-lattice coupling. It is therefore sensitive to the am ount of doping and to the details of the structure, but also to m agnetic elds : the insulating CO state can 'm elt' into a m etallic state by polarizing the M n m om ents and prom oting the m obility of the e<sub>g</sub> electron on the M n<sup>3+</sup> -sites. This m agnetic

eld-driven insulator-m etal transition leads to 'Colossal' magnetoresistance e ects [1]. A much studied and quite robust CO-system is  $Pr_{0.5}Ca_{0.5}MnO_3$ . In the bulk, charge order sets in at 240 K, accompanied by orbital ordering of the  $e_g$ -orbitals [2] and an increased distortion of the orthorhom bic unit cell [3]. The melting is hysteretic, with eld values at low temperatures of about 27 T (increasing eld) and 20 T (decreasing eld) [4]. In thin 1m form,

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the developm ent and stability of the CO state has been much less studied. A special issue concerns the e ects of strain. G iven the strong electron-lattice coupling, it can be expected that strained lms show properties di erent from the bulk materials. This is the case, for instance, in tensile strained lms of  $La_{0:73}Ca_{0:27}M nO_3$  on SrT iO<sub>3</sub> (STO), where very thin (5 nm) lms show a Jahn-Teller-like deform ed structure, and are insulating rather than metallic [5]. Strain release in thicker lms then brings back the bulk properties. Strain should also be present in  $Pr_{0:5}Ca_{0:5}M nO_3$  (pseudocubic lattice parameter a = 0.381 nm) grown on STO (a = 0.391 nm). Recently reported results on this combination demonstrated strongly reduced melting elds [6,7] for lms in a thickness range 75 nm -100 nm, which was ascribed to the fact that the distortions norm ally induced by the CO state cannot fully develop due to the strain in posed by the substrate.

In the present work, we report on a similar study on  $Pr_{0.5}Ca_{0.5}M nO_3$  (PCMO) thin lms of varying thickness, deposited on STO-[100] by dc magnetron sputtering, but we come to a di erent conclusion. At small thickness (25 nm) the strained lms still require high CO melting elds H<sub>m</sub> of the order of 20 T, quite close to the value of bulk single crystals [4]. W ith increasing lm thickness, the strain relaxes but the bulk-like behavior is increasingly lost; still, in the thickness range around 80 nm, H<sub>m</sub> is signi cantly higher than found in refs [6,7]. At thicknesses around 150 nm the lms are almost free of strain and H<sub>m</sub> at 50 K has reduced to 4 T, with a strong increase in the hysteretic behavior and the appearance of a ferrom agnetic signal. The data suggest that the strain itself does not in pede form ation of the CO state, but that the relaxation leads to the observed reduction of H<sub>m</sub>, presum ably due to the generation of lattice defects. This conclusion is supported by the behavior of lms which are post-annealed or grown on YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub> (YBCO) as tem plate layer: such lm s are more relaxed than when grown directly on STO and shows correspondingly sm aller values for H<sub>m</sub>.

Experimental. { All Instudied were sputter deposited from ceramic targets of nom inally  $Pr_{0.5}Ca_{0.5}M$  nO<sub>3</sub> and YBa<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub> on STO substrates, in a pure oxygen atmosphere of 300 P a with a substrate-source on-axis geom etry. The high pressure leads to a very low grow th rate of 0.4 nm /m in and 2.5 nm /m in for PCM 0 and YBC0 respectively. Bilayers were grow n by rotating the sample from one target position to the other. The growth temperature was chosen at 840 C, in order to be able to grow high-quality Im s of both m aterials at identical condition. The samples were cooled to room temperature after deposition without postannealing, which leads to non-superconducting YBCO<sub>7</sub> with = 0.53 (as determ ined from the lattice param eter). Magnetotransport measurements up to 9 T were performed with an autom ated m easurem ent platform (called PPM S); m agnetization up to 5 T w as m easured with a SQUID-based magnetom eter (both from Quantum Design). Measurements in elds above 9 T were performed in a Bitter magnet at the High Field Magnet Laboratory (Nijmegen). The crystal structure and lattice parameters were characterized by X-ray di raction, with the lattice parameters out-of-plane determ ined from the  $(010)_{c}$ ,  $(020)_{c}$  and  $(030)_{c}$  re ections (c refers to the pseudocubic cell, with the b-axis taken perpendicular to the substrate), and in-plane from the  $(013)_c$  and  $(023)_c$  re ections.

Results and discussion. { The structure of bulk PCMO is orthorhom bic (Pnma) with a = 0.5395 nm, b = 0.7612 nm and c = 0.5403 nm [8]. In terms of a pseudocubic lattice parameter  $a_c$ , this means a slight di erence between the a-c plane ( $a_c = 0.3818 \text{ nm}$ ) and the b-axis ( $a_c = 0.3806 \text{ nm}$ ). Electron di raction to determ ine the lm orientation showed that for thin lms (below roughly 80 nm) the [010] axis of the lm is perpendicular to the substrate, in accordance with the ndings of ref. [6]. For thick lms (150 nm) the preferential orientation is the same, but domains with the [010]-axis in the substrate plane are also found. The thickness dependence of in-plane and out-of-plane lattice parameters  $a_{c;in ;out}$  is plotted

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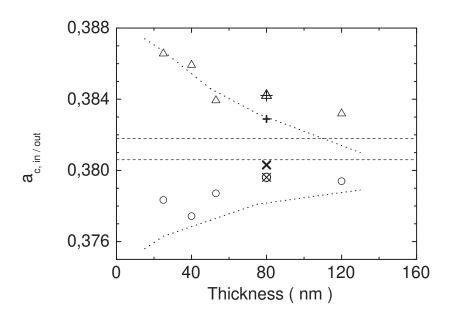


Fig. 1 { Lattice parameters ( : out-of-plane  $a_{c;out}$ ; 4 : in-plane  $a_{c;in}$ ) for  $lm s of Pr_{0:5}Ca_{0:5}M nO_3$  with di erent thickness. The dotted lines show the behavior for  $a_{c;in;out}$  as found in ref. [6]. The horizontal dashed lines indicate the bulk values. The symbols circle/plus and triangle/cross denote a 1-hour post-annealed lm of 80 nm; (+,x) denote the same lm after a 5-h post-anneal.

in Fig.1. At low thickness  $a_{c;in}$  is closer to the (larger) substrate value than to the bulk value, while  $a_{c;out}$  is smaller than the bulk value, indicating that the lm s grow epitaxially and strained. W ith increasing thickness both lattice parameters tend towards the bulk values. The behavior is quite similar to that reported in ref. [6] as indicated by the dotted lines in Fig.1. The full-width-at-half-maximum of the rocking curve of the (020) peak for all lm s is smaller than 0.5, indicating good crystallinity.

All In s showed semiconductor-like insulating behavior in zero applied magnetic eld, as illustrated in Fig. 2a,b for Im s of 80 nm and 150 nm. An anomaly is present in the logarithm ic derivative dR =d (1=T) around a value expected for the CO transition temperature  $T_{co}$ , but without the jump which is prominently observed in bulk material at 240 K. The absence of this jump is probably due to the fact that the increase of the in-plane lattice parameter which accompanies the charge ordering is already accom odated by the substrate strain [9]. The CO transition is visible in the magnetization M, especially for the thicker Im s. As shown in the inset of Fig. 2b, M (T) for the 150 nm Im in a eld of 1 T shows a clear shoulder around 240 K, rem iniscent of the peak in the susceptibility found in the bulk

For lm s of 25 nm, the resistance drop in a magnetic eld, which signi es the CO melting, was found at temperatures below 100 K near the maximum available eld of 20 T for one sample, while a second one did not show a change in R up to 20 T. Also, R (H) is hysteretic: upon decreasing the eld the resistance jumps back up at a lower eld, as expected since the

m aterial at  $T_{co}$  (and above the magnetic transition) [10].

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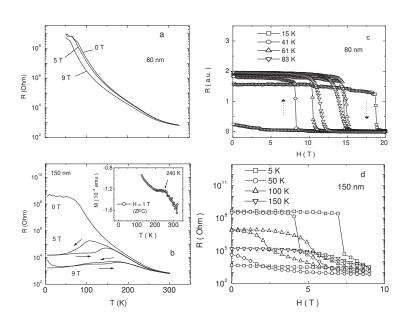


Fig. 2 { Resistance R versus temperature T at magnetic elds H = 0, 5, 9 T for lm s of Pr<sub>0:5</sub>Ca<sub>0:5</sub>MnO<sub>3</sub> with thickness (a) 80 nm, (b) 150 nm; for the same lm s R versus H at dierent T as indicated, (c) 80 nm, (d) 150 nm

melting transition is rst order. We denote the upper and lower critical elds as  $H_c^+$  and  $H_c^-$  respectively. W ith increasing thickness, both branches shift to lower elds. Examples of R (H) for the lm s of 80 nm and 150 nm are given in Fig. 2c,d. For the lm of 150 nm the melting eld has dropped to only 5 T around 50 K. The resistance changes are sharp, making  $H_c$  well-de ned, and the curves can be used to construct the tem perature- eld phase diagram s [11] shown in Fig 3, where at zero eld the value of the bulk is used. The shape of the phase diagram s changes signi cantly with increasing thickness. For the 25 nm lm, hysteresis is only present below 70 K in the eld region 16 T - 20 T. These large values resemble the numbers found for bulk single crystals. For the 80 nm lm hysteresis starts below 130 K and the di erence between the (+; )-branches increase considerably, especially at low tem peratures; the  $H_c^+$  branch is still above 12 T at all tem peratures, which explains the sm all M R e ects seen in Fig.2a. B oth  $H_c^+$  and  $H_c^-$  are considerably larger than reported in ref [7]. In the 150 nm lm hysteresis is found below 175 K. B oth branches have shifted to lower elds :  $H_c^+$  is curved with a minimum value of 4 T around 50 K, while  $H_c^-$  now lies at zero eld for tem peratures below 80 K.

The melting transition is insulator-metal, but also antiferrom agnetic-ferrom agnetic, and can therefore be seen in the eld dependence of the magnetization. Fig. 4a shows M (H) of the 150 nm lm at 100 K, for the eld sequence 0 T ! + 5 T ! -5 T ! + 5 T, with the diamagnetic substrate signal subtracted. A sm all ferrom agnetic component is already present in

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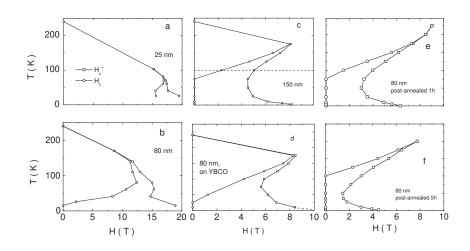


Fig. 3 { Charge order melting eld phase diagram s as determ ined from the magnetoresistance for lm s of di erent thickness. The point at zero eld is the bulk value for  $T_{co}$ . (a) 25 nm; (b) 80 nm; (c) 150 nm; (d) 80 nm, grown on YBCO template; (e) 80 nm post-annealed 1h; (f) 80 nm post-annealed 5h. The dashed line in (c) denotes the tem perature of the magnetization measurem ents given in Fig. 4

the virgin state; with increasing eld M (H) is constant until 1.8 T and then rises signi cantly when the eld is increased to 5 T.Upon decreasing the eld M now remains constant because the sample is in the FM state, but starts to drop around 3 T when  $H_c$  is crossed as can be seen in Fig 3c (dotted line). At zero eld, the ferrom agnetic component has grown by m ore than a factor 2. The same behavior is found when continuing the loop to -5 T; when going back up to +5 T, M m erges with the virgin curve above 4 T.

The rst conclusion we draw is that the CO state in the strained material is hardly less stable (if at all) than in the bulk. This is di erent from the one reached in Refs. [6,7], but it is in good agreement with the data reported on Cr-doped Ims [9]: in that case it was found that strain-free Ims very quickly developed ferrom agnetism upon Cr-doping, but that Cr-doped Ims under tensile strain were still insulating, suggesting that the strain counteracts the e ects of the Cr doping and stabilizes the CO state. The decreasing stability of the CO state with increasing Im thickness appears due to the strain relaxation rather than the strain itself. The picture arising then is that defects (disorder) induced by the growth and the relaxation destabilize CO, but that the strain itself that no destabilizing e ect or even the opposite, which is quite reasonable in view of the fact that the necessary lattice distortion is already accomm odated (also suggested in ref. [9]).

In order to highlight the e ects of strain relaxation we perform ed two more experiments. One 80 nm In was annealed in the growth chamber for one hour at 950 C in 1 m bar  $O_2$ (the sputtering pressure) and slow ly cooled; after measuring it was annealed for an additional 5 hours in owing oxygen at 900 C. Another 80 nm In was grown on a 10 nm YBCO template layer (called PY) since in previous work [12] we found that YBCO is an elective

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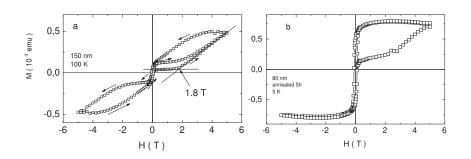


Fig. 4 { Magnetization M versus magnetic eld H for  $\ln s$  of Pr<sub>0.5</sub>Ca<sub>0.5</sub>M nO<sub>3</sub>. In both cases, the magnetization of the substrate has been subtracted. (a)  $\ln s$  of 80 nm at 100 K; (b)  $\ln s$  of 80 nm, post-annealed for 5h, at 5 K.

strain relaxor for  $La_{0:67}Ca_{0:33}M$  nO<sub>3</sub>. Both m ethods e ectively relax the strain in PCMO as well. Lattice parameter values ( $a_{c;out}$ ,  $a_{c;in}$ ) are (0.384 nm, 0.380 nm) for the 1-hour post-annealed sample, (0.383 nm, 0.380 nm) for the 5-hour post-annealed sample, and (0.385 nm, 0.380 nm) for PY, showing that all have undergone relaxion, especially in the out-of-plane axis. The CO-m elting phase diagrams for these samples again show a strong decrease of the melting elds (see Fig. 3d-f), with the 5-hour post-annealed sample reaching the lowest value yet observed in this system (1.5 T at about 50 K). The eld dependence of the magnetization e.g. at 5 K (Fig. 4b) accordingly shows an increase of M around 3 T (due to the bending back of the H  $_c^+$ -branch), but no decrease of M from 5 T dow nw ard until the ferrom agnetic hysteresis regime is entered, since H  $_c^-$  now lies at 0 T.

Since relaxation by post-annealing must be accompanied by inducing defects in the lm , the observations reinforce the notion that defects are responsible for the change in melting behavior. In this respect it is in portant to note that the developm ent of the phase diagram s presented in Fig. 3 closely resembles the changes found in the bulk material when going from x = 0.5 (sm all hysteretic regime at a large eld) to x = 0.3 (curved upper branch at relatively low elds and lower branch going to zero) [1]; especially the sim ilarity between the behavior of the 5h post-annealed Im and the x = 0.3 bulk material is striking, with both showing a m inim um H $_{\rm c}^+$  eld of about 2 T around 30 – 40 K, and the H $_{\rm c}$ -branch at zero eld. Still, the physics behind this may not be quite the same. In the bulk case, the change of doping induces discommensurations and a canted antiferrom agnetic (c-a-f) state. In the lm s the am ount of carriers is not changed; rather it is the local structure which can vary, which would in uence the local Jahn-Teller distortions and the concom mittant orbital order. This would in turn promote ferrom agnetic interactions, possibly leading to ferrom agnetic clusters in a phase-separation-like scenario very sin ilar to the disorder-driven phase separation observed in  $\text{Im s of La}_{0.67}\text{Ca}_{0.33}\text{M nO}_3$  [13]. We observe that the structure relaxation is accompanied by an increasing am ount of ferrom agnetic component in the magnetization, which could be either due to the c-a-f state or to ferrom agnetic clusters. The answer to this question m ay com e from electron m icroscopy studies, which are now in progress. Finally, we note that dis-

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order as a m a pr source for reduced m elting elds can also explain the di erence between our results and those of ref. [6,7] as caused by the di erent morphology of the sputtered versus the laser-ablated lm s. This suggests that the CO state is more sensitive to disorder than m ight be assumed in view of the high melting elds, and that if CO lm s are to be grown, avoiding disorder is the m a pr source of concern.

In summary, we have shown that the melting elds  $H_m$  for the insulating CO state in  $Pr_{0.5}Ca_{0.5}M nO_3$  In s under tensile strain are around 20 T or even above, rather close to the values found for the bulk material. Strain relaxation strongly reduces  $H_m$ . W ith increasing Im thickness, the lattice parameters of the Im demonstrate relaxation, while  $H_m$  decreases down to 4 T at 50 K for a 150-nm Im. Upon strain relaxation by post-annealing this value becomes even smaller. We suggest this is due to induced defects, which destabilize the antiferrom agnetic state and possibly even promote the form ation of ferrom agnetic clusters.

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